

CLAIMS

What is claimed is:

1. A wavelength-dependent, optical-signal detector, comprising:
 - a) a semiconductor substrate with a surface;
 - b) a comb-like metal electrode deposited in at least one layer located above said surface of said semiconductor substrate, said comb-like metal electrode comprising a plurality of arms at a common voltage;
 - c) a voltage means; and
 - d) a plurality of metal electrodes deposited in at least one layer located above said surface of said semiconductor substrate and interdigitated between said arms of said comb-like metal electrode, said metal electrodes connected to said voltage means to provide each of said metal electrodes with a control voltage, said control voltage provided to each of said metal electrodes chosen to control collection and superposition of charge carriers produced in said wavelength-dependent, optical-signal detector by an optical signal, thereby selecting a wavelength to be detected with said wavelength-dependent, optical-signal detector.
2. The wavelength-dependent, optical-signal detector of claim 1 wherein said comb-like metal electrode and said metal electrodes are substantially coplanar.
3. The wavelength-dependent, optical-signal detector of claim 1 wherein said comb-like metal electrode further comprises at least five arms.

1 4. The wavelength-dependent, optical-signal detector of claim 1 wherein said
2 metal electrodes further comprise at least four electrodes.

1 5. The wavelength-dependent, optical-signal detector of claim 1 further
2 comprising at least one opaque masking layer deposited in at least one layer
3 located above said surface of said semiconductor substrate such that a pair of
4 electrodes, comprising one of said arms of said comb-like metal electrode and
5 one of said metal electrodes, is separated from neighboring electrodes by said
6 opaque masking layer.

1 6. The wavelength-dependent, optical-signal detector of claim 1 where in said
2 semiconductor substrate is selected from the group consisting of GaAs and
3 InP.

1 7. The wavelength-dependent, optical-signal detector of claim 1 further
2 comprising a base layer, with a surface, deposited at a location above said
3 surface of said semiconductor substrate and below said layer containing said
4 comb-like metal electrode and said layer containing said metal electrodes.

1 8. The wavelength-dependent, optical-signal detector of claim 7 where in
2 said base layer is selected from the group consisting of GaAs, InGaAs,
3 AlGaAs and InP.

1 9. The wavelength-dependent, optical-signal detector of claim 7 further
2 comprising an intermediate layer, with a surface, deposited at a location
3 above said surface of said base layer and below said layer containing

4 said comb-like metal electrode and said layer containing said metal
5 electrodes.

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1 10. The wavelength-dependent, optical-signal detector of claim 9
2 where in said intermediate layer is selected from the group
3 consisting of InAlAs, GaAs, AlGaAs and InGaAs.

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1 11. The wavelength-dependent, optical-signal detector of claim 9
2 further comprising a top layer deposited at a location above said
3 surface of said intermediate layer and below said layer
4 containing said comb-like metal electrode and said layer
5 containing said metal electrodes.

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1 12. The wavelength-dependent, optical-signal detector of
2 claim 11 where in said top layer is selected from the
3 group consisting of GaAs and InAlAs.

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1 13. The wavelength-dependent, optical-signal detector of claim 1 wherein said
2 voltage means comprises separate voltage sources for providing a separate
3 control voltage to each of said metal electrodes.

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1 14. The wavelength-dependent, optical-signal detector of claim 1 wherein said
2 comb-like metal electrode is connected to an amplifier for amplifying.

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1 15. The wavelength-dependent, optical-signal detector of claim 14 wherein
2 said amplifier is a trans-impedance amplifier.

1 16. The wavelength-dependent, optical-signal detector of claim 1 wherein
2 production of said charge carriers in response to said optical signal in regions in
3 said wavelength-dependent, optical-signal detector is enabled and production of
4 said charge carriers in response to said optical signal in other regions in said
5 wavelength-dependent, optical-signal detector is disabled.

1 17. The wavelength-dependent, optical-signal detector of claim 16 wherein
2 a standing wave pattern obtained from said optical signal enables and
3 disables production of charge carriers in response to said optical signal
4 in said regions and said other regions in said wavelength-dependent,
5 optical-signal detector.

1 18. The wavelength-dependent, optical-signal detector of claim 17
2 wherein an interferometer produces said standing wave pattern.

1 19. The wavelength-dependent, optical-signal detector of claim 17
2 wherein said standing wave pattern is positioned relative to said
3 metal electrodes and said comb-like metal electrode to enable
4 detection of said wavelength in said wavelength-dependent,
5 optical-signal detector.

1 20. An optical system, comprising:

- 2 a) a stream of light with a plurality of wavelengths containing information; and
- 3 b) at least one wavelength-dependent detector having a set of electrodes for
4 switching between wavelengths, wherein charge carriers produced by said
5 stream of light in said wavelength-dependent detector are collected and
6 superposed in response to a set of control voltages applied to said set of

7 electrodes in said wavelength-dependent detector by a voltage means, wherein a
8 wavelength to be detected predetermines said set of control voltages applied to
9 said set of electrodes.

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1 21. The optical system of claim 20 wherein RC time constant of said wavelength-
2 dependent detector provides for switching between wavelengths in less than 10
3 ns.

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1 22. The optical system of claim 20 further comprising at least one amplifier.

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1 23. The optical system of claim 22 wherein said amplifier is a trans-
2 impedance amplifier.

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1 24. The optical system of claim 20 further comprising at least one dispersion
2 device for spatially segregating said light stream.

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1 25. The optical system of claim 24 wherein said dispersion device is
2 selected from the group consisting of a diffraction grating, a prism and
3 an array waveguide grating.

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1 26. The optical system of claim 20 further comprising a plurality of wavelength-
2 dependent detectors, each of which is used to detect a range of wavelengths.

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1 27. The optical system of claim 20 further comprising at least one lens to focus
2 said stream of light onto said wavelength-dependent detector.

1 28. The optical system of claim 20 further comprising at least one standing-wave
2 generator for generating a wavelength-dependent, spatially varying light
3 intensity.

1 29. The optical system of claim 28 wherein angle of incidence of at least
2 two beams in said stream of light to said wavelength-dependent
3 detector determines position and period of said spatially varying light
4 intensity relative to said set of electrodes in said wavelength-dependent
5 detector.

1 30. The optical system of claim 28 wherein said standing-wave generator is
2 an interferometer.

1 31. The optical system of claim 30 wherein optical path length
2 difference in said interferometer determines position of said
3 spatially varying light intensity relative to said set of electrodes
4 in said wavelength-dependent detector.

1 32. The optical system of claim 30 wherein channel spacing is
2 determined by path length difference in said interferometer.

1 33. The optical system of claim 20 wherein information in said stream of light is
2 encoded with a technique selected from the group consisting of time domain
3 multiplexing, frequency domain multiplexing, time domain and frequency
4 domain multiplexing, spread-spectrum encoding and iterative coding.

34. The optical system of claim 33 wherein spread-spectrum encoding is code division multiple access.

35. The optical system of claim 20 wherein said optical system is at least part of a system selected from the group consisting of DWDM, CWDM, WDM, a spectrometer, an optical interconnect and an optical sensor.

36. The optical system of claim 20 wherein said wavelength-dependent detector comprises:

a) a semiconductor substrate with a surface;

b) a comb-like metal electrode deposited in a layer located above said surface of said semiconductor substrate, said comb-like metal electrode comprising at least five arms at a common voltage;

c) a voltage means;

d) at least four metal electrodes deposited in a layer located above said surface of said semiconductor substrate, substantially coplanar with said comb-like metal electrode and interdigitated between said arms of said comb-like metal electrode, each of said metal electrodes connected to said voltage means which provides said set of control voltages to said metal electrodes; and

e) a trans-impedance amplifier connected to said comb-like metal electrode.

37. The optical system of claim 36 further comprising at least one opaque masking layer deposited in a layer located above said surface of said semiconductor substrate such that a pair of electrodes, comprising one of said arms of said comb-like metal electrode and one of said metal

5 electrodes, is separated from neighboring electrodes by said opaque
6 masking layer.

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1 38. The optical system of claim 36 wherein said voltage means comprises
2 separate voltage sources for providing a separate control voltage in said
3 set of control voltages to each of said metal electrodes.

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1 39. The optical system of claim 38 wherein said semiconductor
2 substrate is taken from the group consisting of GaAs and InP.

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1 40. The optical system of claim 36 further comprising a base layer, with a
2 surface, deposited at a location above said surface of said
3 semiconductor substrate and below said layer containing said comb-like
4 metal electrode and said layer containing said metal electrodes.

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1 41. The optical system of claim 40 where in said base layer is taken
2 from the group consisting of GaAs, InGaAs, AlGaAs and InP.

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1 42. The optical system of claim 40 further comprising an
2 intermediate layer, with a surface, deposited at a location above
3 said surface of said base layer and below said layer containing
4 said comb-like metal electrode and said layer containing said
5 metal electrodes.

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1 43. The optical system of claim 42 where in said
2 intermediate layer is taken from the group consisting of
3 InAlAs, GaAs, AlGaAs and InGaAs.

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1 44. The wavelength-dependent, optical-signal detector of
2 claim 42 further comprising a top layer deposited at a
3 location above said surface of said intermediate layer and
4 below said layer containing said comb-like metal
5 electrode and said layer containing said metal electrodes.
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1 45. The wavelength-dependent, optical-signal
2 detector of claim 44 where in said top layer is
3 selected from the group consisting of GaAs and
4 InAlAs.
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1 46. A method of detecting a wavelength of light with a wavelength-dependent detector,
2 comprising:
3 a) illuminating said wavelength-dependent detector with said light containing said
4 wavelength;
5 b) connecting said wavelength-dependent detector to a voltage means; and
6 c) setting a control voltage on each of a plurality of metal electrodes interdigitated
7 with a plurality of arms in a comb-like metal electrode in said wavelength-
8 dependent detector with said voltage means, said control voltage set on each of
9 said metal electrodes controlling collection and superposition of charge carriers
10 produced in said wavelength-dependent detector by said light, thereby selecting
11 said wavelength.
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1 47. The method of claim 46 further comprising the step of connecting said comb-
2 like metal electrode in said wavelength-dependent detector to an amplifier.
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1 48. The method of claim 46 further comprising the step of selecting said
2 wavelength of said light by spatially segregating said light with a dispersion
3 device.

1 49. The method of claim 46 further comprising the step of producing a spatially
2 varying intensity of said light on said wavelength-dependent detector by
3 passing said light through an interferometer.

1 50. The method of claim 49 further comprising the step of setting position
2 of said spatially varying light intensity relative to said metal electrodes
3 in said wavelength-dependent detector by adjusting angle of incidence
4 of at least two beams in said light to said wavelength-dependent
5 detector.

1 51. The method of claim 49 further comprising the step of setting position
2 and period of said spatially varying light intensity relative to said metal
3 electrodes in said wavelength-dependent detector by adjusting optical
4 path length difference in said interferometer.

1 52. The method of claim 49 further comprising the step of adjusting
2 channel spacing by changing path length difference in said
3 interferometer.